



## First Korea-Japan Joint Workshop on Pattern Recognition

November 23-24, 2006  
Jeju Poonglim Resort, Jeju Island, Korea

Hosted by KISS SIG-CVPR and IEICE PRMU Group



## 2006 年度 11 月 PRMU 研究会（韓国開催）のご案内

<http://cv.chonbuk.ac.kr/~kjpr/>

PRMU 研究会では、韓国情報科学会 SIG-CVPR と共催で、11 月 23 日、24 日の 2 日間にわたり、テーマセッション「日本・韓国における PRMU 技術の産業応用」を開催することになりました。研究会は国際セッションと母国語セッションから構成されています。母国語セッションは、開催地が海外であることを除けば通常の PRMU と同一ですが、国際セッションは、PRMU 研究会のセッションであると同時に、First Korea-Japan Joint Workshop on Pattern Recognition としても開催されます。国際セッションでは、一般講演（査読付き論文に対する講演）に加え、以下のような豪華な講師の方々による講演を予定しております。

## キーノート講演：

Prof. Dan Lopresti (Lehigh University, USA),

“Evaluating Biometric Security: Understanding the Impact of Wolves in Sheep's Clothing” (仮題)

Prof. Kar-Ann Toh (Yonsei University, Korea), “Pattern Classification and Biometric Decision Fusion”

オーガナイズドセッション：「パターン認識技術の産業応用」講師の方々（ABC 順；敬称略）

☐ 堀 修（東芝），堀越 力（NTT DoCoMo），鹿毛 裕史（三菱電機），  
直井 聡（富士通研究所），新庄 広（日立），山田 敬嗣（NEC）

☐ Sung-Jung Cho (Samsung), Byung-Hee Jung (KBS), Hoyon Kim (ETRI)

Junhwan Kim (Olaworks), Won Young Yoo (ETRI)

母国語セッションは通常の PRMU と同一の手続きでご参加いただけますが、国際セッションでは査読を行うため、**通常の PRMU とは投稿方法が異なります**。次の点にご注意いただき、奮ってご投稿・ご参加ください。

	国際セッション	母国語セッション
言語	英語	日本語
論文ページ数	6 ページ	
スタイルファイル	<a href="http://www.ieice.org/iss/prmu/jpn/kjpr/">http://www.ieice.org/iss/prmu/jpn/kjpr/</a> から取得	通常の PRMU と同じ
査読	あり	なし
発表申込	<b>9 月 22 日 extended!</b>	
申込先	<a href="http://www.ieice.org/ken/program/index.php?tgid=PRMU">http://www.ieice.org/ken/program/index.php?tgid=PRMU</a>	
投稿締切	<b>9 月 22 日（申込時に論文も投稿） extended!</b>	
投稿方法	PDF ファイルをメール添付で次のアドレスに送付 prmu-kjpr-submit@mail.ieice.org	通常の PRMU と同じ
査読結果通知	10 月 10 日	
カメラレディ	10 月 20 日	通常の PRMU と同じ
参加費	無料	
論文集	電子情報通信学会技術研究報告として出版	
問い合わせ先	prmu-kjpr-jp-inquiries@mail.ieice.org（日本語でどうぞ）	

**Advisory Co-Chairs** : Jin-Hyung Kim (KAIST, Korea), Masaki Nakagawa (Tokyo Univ. of Agriculture and Technology, Japan)

**Co-Chairs of the workshop**: Il-Seok Oh (Chonbuk National Univ., Korea), Hiroshi Murase (Nagoya Univ., Japan)

**Program Committee Members**: Hyeran Byun (Yonsei Univ.), Sung-Jung Cho (Samsung), Joongmin Choi (Hanyang Univ.), Yeongwoo Choi (Sookmyung Women's Univ.), Simon Clippingdale (NHK), Young-Sup Hwang (Sunmoon Univ.), Toshiki Iso (NTT DoCoMo), Shigeyoshi Hiratsuka (Toyota Central R&D Labs.), Hang-Joon Kim (Kyungpook National Univ.), Soo-Hyung Kim (Chonnam National Univ.), Masatoshi Kimachi (Omron), Koichi Kise (Osaka Prefecture Univ.), Itaru Kitahara (Univ. of Tsukuba/ATR), Young Tae Lee (Inzisoft), Seong-Whan Lee (Korea Univ.), Yoshito Mekada (Chukyo Univ.), Sung Hyon Myaeng (ICU), Yuichi Nakamura (Kyoto Univ.), Weon-Geun Oh (ETRI), Shinichiro Omachi (Tohoku Univ.), Sung-Choon Park (KBS), Jung-hee Ryu (Olaworks), Shin'ichi Satoh (NII), Yoichi Sato (Tokyo Univ.), Makito Seki (Mitsubishi Electric), Shuji Senda (NEC), Hiroshi Shinjo (Hitachi), Bong-Keek Sin (Pukyung National Univ.), Kazuhiko Sumi (Mitsubishi Electric/Kyoto Univ.), Seiichi Uchida (Kyushu Univ.), Osamu Yamaguchi (Toshiba), Megumi Yamaoka (Matsushita Electric Industrial), Byoung-Tak Zhang (Seoul National Univ.)

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KAIST, Korea

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Tokyo Univ. of Agriculture and Technology,  
Japan

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Hiroshi Murase  
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Pukyung National Univ., Korea

Koichi Kise  
Osaka Prefecture Univ., Japan

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Simon Clippingdale  
NHK, Japan

Young-Sup Hwang  
Sunmoon Univ., Korea

Toshiki Iso  
NTT DoCoMo, Japan

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Sung Hyon Myaeng  
ICU, Korea

Yuichi Nakamura  
Kyoto Univ., Japan

Weon-Geun Oh  
ETRI, Korea

Shinichiro Omachi  
Tohoku Univ., Japan

Sung-Choon Park  
KBS, Korea

Jung-hee Ryu  
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Shin'ichi Satoh  
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Hiroshi Shinjo  
Hitachi Central Research Lab., Japan

Kazuhiko Sumi  
Mitsubishi Electric / Kyoto Univ., Japan

Seiichi Uchida  
Kyushu Univ., Japan

Osamu Yamaguchi  
Toshiba, Japan

Megumi Yamaoka  
Matsushita Electric Industrial, Japan

Byoung-Tak Zhang  
Seoul National Univ., Korea



# First Korea-Japan Joint Workshop on Pattern Recognition

November 23-24, 2006  
Jeju Poonglim Resort, Jeju Island, Korea

Hosted by KISS SIG-CVPR and IEICE PRMU Group



The first Korea-Japan joint workshop on pattern recognition is organized by leading scientific societies SIG-CVPR of KISS, Korea and PRMU of IEICE, Japan, as a first step towards an Asian-wide conference on pattern recognition. This workshop will give opportunities not only for sharing and exchanging original research results and practical experiences but also for bringing together researchers and practitioners from both Korea and Japan.

## Topics of interest

The scope of the workshop is not limited to a specific area but covers a broad range of theories and applications of pattern recognition, including but not limited to various media understanding such as video and documents, bioinformatics, pattern recognition technologies for security and ubiquitous media, human interaction, learning theories and their applications, robotics and pattern recognition.

## Workshop format

This will be a two-day workshop with the following sessions: keynote lectures, an organized session and general sessions all of which will be presented in English. The keynote lectures will be given by Prof. Dan Lopresti of Lehigh University, USA, and Prof. Kar-Ann Toh of Yonsei University, Korea. The organized session consists of presentation about the topic "industrial applications of pattern recognition technologies" by guest speakers from Korean and Japanese industries. Submitted papers will be presented in the general sessions.

### ► Keynote lecture

Dan Lopresti (Lehigh University, USA),

"Evaluating Biometric Security: Understanding the Impact of Wolves in Sheep's Clothing"

Kar-Ann Toh (Yonsei University, Korea), "Pattern Classification and Biometric Decisions Fusion"

### ► International Organized Session

Topic: "Industrial Applications of Pattern Recognition Technologies"

Guest speakers:



From Korea:

Sung-Jung Cho (Samsung)

Byung-Hee Jung (KBS)

Hoyon Kim (ETRI)

Junhwan Kim (Olaworks)

Won Young Yoo (ETRI)



From Japan:

Osamu Hori (Toshiba)

Tsutomu Horikoshi (NTT DoCoMo)

Hiroshi Kage (Mitsubishi Electric)

Satoshi Naoi (Fujitsu Laboratories)

Hiroshi Shinjo (Hitachi)

Keiji Yamada (NEC Corporation)

## Publication



For Korean and other countries' participants:

The proceedings are published as International workshop of SIG-CVPR.



For Japanese participants:

The proceedings are published as technical reports of PRMU.

## Submission Information



For Korean and other countries' authors:

Papers should be written in English within the limit of 6 printed pages and submitted via workshop web site in camera-ready format. The Word template is available at <http://cv.chonbuk.ac.kr/~kjpr/>.



For Japanese authors:

Papers should be written in English within the limit of 6 printed pages and submitted via email to [prmu-kjpr-submit@mail.ieice.org](mailto:prmu-kjpr-submit@mail.ieice.org) in camera-ready format. Both the style file for LaTeX and the Word template are available at <http://www.ieice.org/iss/prmu/jpn/kjpr/>.

Note that only PDF files are accepted. It is also requested to input information about your submission at <http://www.ieice.org/ken/program/index.php?tid=PRMU>.

## Important Dates

Paper submission:

September 22, 2006

Author notification:

October 10, 2006

Camera-ready paper due:

October 20, 2006

Extended!

## Information

<http://cv.chonbuk.ac.kr/~kjpr/>

## Inquiries

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